CLAIMS

What is claimed is:

		·
1	1.	An integrated circuit chip comprising:
2		a logic core;
3		a plurality of insulating and conducting levels above said core;
4		an exterior conductor level above said insulating and conducting levels; and
5		passive devices comprising a conductive polymer directly connected to said exterior
6	conductor level.	
1	2.	The integrated circuit chip in claim 1, wherein said passive devices comprise RF devices.
1	3.	The integrated circuit chip in claim 1, wherein said passive devices comprise at least one
2	of resistors, capacitors, and inductors.	
1	4.	The integrated circuit chip in claim 3, wherein said resistors comprise serpentine
2	resistors.	
1	5.	The integrated circuit chip in claim 3, wherein said capacitors comprise interdigitated
2	capacitors.	

An integrated circuit chip comprising: 1 6. 2 a logic core; a plurality of insulating and conducting levels above said core; 3 an exterior conductor level above said insulating and conducting levels; 4 passive devices comprising a conductive polymer directly connected to said exterior 5 6 conductor level; and 7 a substrate connected to said passive devices on a side of said passive devices opposite from said exterior conductor level. 8 The integrated circuit chip in claim 6, wherein said passive devices comprise RF devices. 1 7. The integrated circuit chip in claim 6, wherein said passive devices comprise at least one 1 8. of resistors, capacitors, and inductors. 2 The integrated circuit chip in claim 8, wherein said resistors comprise serpentine 1 9. 2 resistors. The integrated circuit chip in claim 8, wherein said capacitors comprise interdigitated 1 10. 2 capacitors.

A method of manufacturing an integrated circuit chip structure comprising: 1 11. supplying an integrated circuit chip; and 2 patterning a conductive polymer on an exterior of said integrated circuit chip, 3 4 wherein said patterning produces passive devices. The method in claim 11, wherein said passive devices comprise RF devices. 1 12. The method in claim 11, wherein said passive devices comprise at least one of resistors, 1 13. 2 capacitors, and inductors. The method in claim 13, wherein said resistors comprise serpentine resistors. 1 14. 1 The method in claim 13, wherein said capacitors comprise interdigitated capacitors. 15. A method of manufacturing an integrated circuit chip structure comprising: 1 16. patterning a conductive polymer on a substrate; and 2 3 bonding said patterned conductive polymer to an integrated circuit chip, 4 wherein said patterning produces passive devices. 1 The method in claim 16, wherein said passive devices comprise RF devices. 17.

- 1 18. The method in claim 16, wherein, said passive devices comprise at least one of resistors,
- 2 capacitors, and inductors.
- 1 19. The method in claim 18, wherein said resistors comprise serpentine resistors.
- 1 20. The method in claim 18, wherein said capacitors comprise interdigitated capacitors.